



RECEIVED

AUG 14 2003

TECH CENTER 1600/2000 PATENT

Customer No. 22,852

Attorney Docket No. 6082-26

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Tadashi Kokubo et al.) Group Art Unit: 1617
)
Application No.: 09/936,166) Examiner: Shahnam J. Sharareh
)
Filed: September 10, 2001)
)
For: Radioactive Microspheres Excellent)
in Chemical Durability and Method)
for Manufacturing the Same)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

REPLY TO OFFICE ACTION

In response to the Office Action of April 9, 2003, the period for response having been extended to August 9, 2003 (Saturday) by a request for extension of one month and fee payment filed concurrently herewith, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks/Arguments follow the amendment sections of this paper.

Attachments to this amendment include:

Pages 1197-1201 of Pure & Appln. Chem., Vol. 57, No. 9, 1985 (Exhibit A); and

Pages 255-259 of Plasma Chemistry and Plasma Processing, Vol. 2, No. 3, 1982

(Exhibit B).